

Title	Operating pr	Operating procedure of EBL 1				10/11/2023	
(Of equipment, plant, experiment, activity, etc.)				Version		1.1	
Activity Details (of equipment, plant, experiment, activity, etc.)	Description	Step wise procedure to operate the EBL 1 tool					
	Location	#160_P3.51H (EBL1)					
	After- Hours Work		YES		\boxtimes	NO	
Photo/s (of equipment, plant, experiment, activity, etc. used as part of this procedure)	EBL1						
Operational requirements	Equipment / F	/ Process / Plant / etc.		Instruction Manual (IM)			
	Cleanroom La	Cleanroom Laboratory Dress Code			IM_160- P3.51_Gowning_Cleanroom_V1.2		
Author/s	Gayatri Vaidy	a		Ph.: 6125 9	9638		

Table of Contents

Pre-operational check	3
OPERATION – List steps to complete the activity from start to finish	3
Sample loading	3
Set up the Beam conditions	6
Set up the Exposure	11
Sample Unloading	13
Sample ready for next processing step	14
Development [Ref. IM _160-P3.51B_WB2]	14
Transport method	15



Waste Disposal	15
Completion of Work	15
Clean up after use	1 -



Describe, in detail and in sequence, the steps involved in this activity

PRE-OPERATIONAL CHECK

Required: user sample Clean and Spin coated

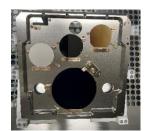
Required: user mask - CAD design

OPERATION - LIST STEPS TO COMPLETE THE ACTIVITY FROM START TO FINISH

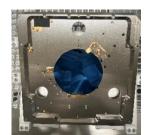
Sample loading

Things needed: Tweezers / sample holder stand / sample holder / resist coated sample

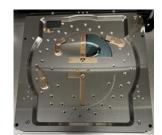
- Select the holder you plan to use
- If required, use Isopropanol (squirt-bottle) and lint-free cloth to wipe holder clean



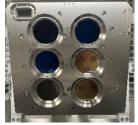
1x4", 3 x 2" combination



Single 2" ~ 6" Wafer



Wafer Piece



2" wafer x 6 slots



Small Pieces 5mm – 1 cm



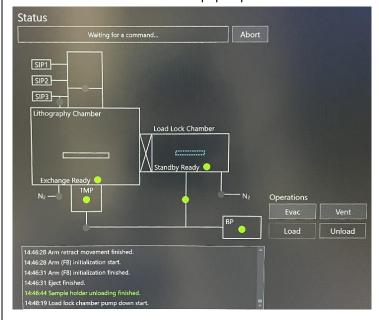
Holder Stand

- Place the selected holder on the stand
- Mount your sample on the holder and clamp it
- N2 blow the sample to get rid of any particles or contaminations present on the sample surface
- Check the display on the screen
- Open the elms Launcher window
- Login to your account

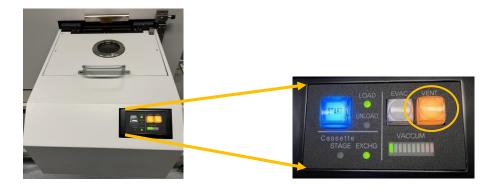




- Click on VAC
- The window seen below pops up



- If the status of the blue plate is in the load lock (LL) chamber as seen in the image above
- Go to the Load Lock chamber and Press Vent



As the chamber is vented the button stops glowing







and lock it using the knob

at the

Open LL lid right corner of the LL





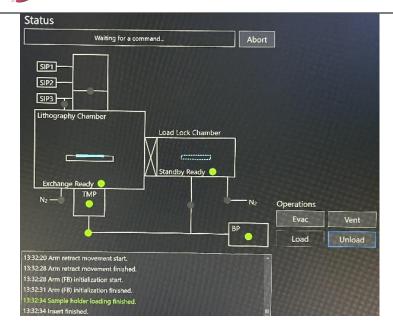


- Load the holder
- Close the lid by unlocking it to unlock tilt it a bit to the back and press the small button on the right-side knob



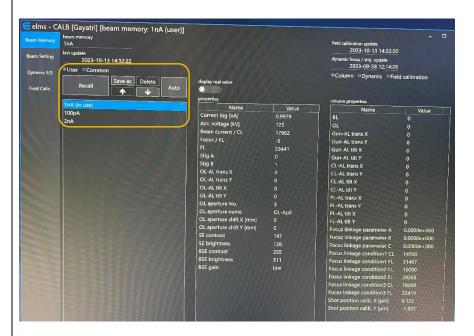
- Press **Start**
- Wait till the blue plate is in the lithography chamber and you get the message "sample holder loading finished" as seen in the image





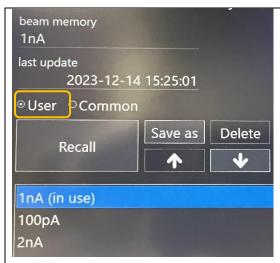
Set up the Beam conditions

- Select the CALB window
- Click on Beam Memory

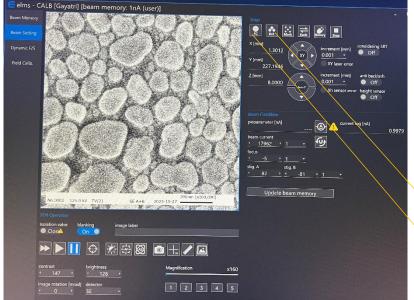


- Check if the USER option is selected
- Choose the current you plan to use and Click on **Recall** For eg. If you Recall 1nA all the settings done at 1nA will be set





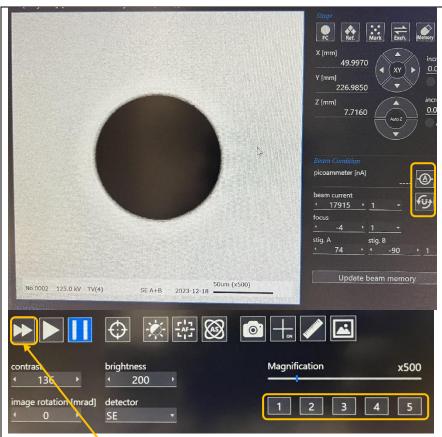
Select Beam Setting





• Click on **FC**, to move the stage for current measurement



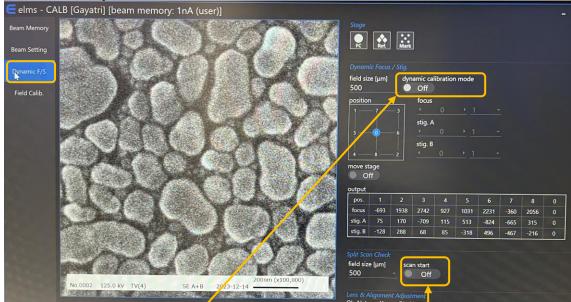


- Click on **Scan**, the FC is visible on the screen as seen above
- Select Mag 2 or 3
- Measure the Current by clicking on
- You can adjust the current if the measured value is low compared to the set value
- Click on to stop the measurement
- Move to Reference Sample
- Select Mag 2 and Scan to check the sample
- Later Select Mag 4/5 to do the corrections
- Click Auto focus (AF)
- Click Auto Stig (AS)
- Click on if you make any changes.
- Update Beam memory
- To move stage position Right Click on the image and select **Stage Moving**, this will move the stage



to the point you click on.

Select Dynamic F/S



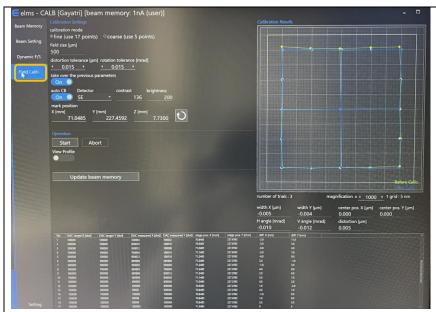
- Click on the Dynamic Calibration Mode
- Click on Scan Start
- This Performs the focusing at the center and 4 corners of the field
- Once the scan is complete, Select the corner that needs correction
- Click on Auto DFocus (AF) and Auto DStig (AS) for all the corners that need correction



- Click on SCAN start again to check the results, if satisfied proceed to next step or repeat the step
- Once satisfied switch off the Scan Start and Dy. calibration buttons
- Click on

 Update beam memory
- Select Field Calib

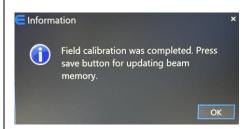




Check the Field selected



• Click on **Start:** This performs the filed alignment and displays the below message once the alignment is complete.

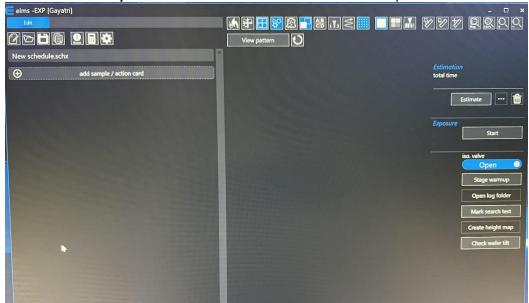


Click On
 Update beam memory

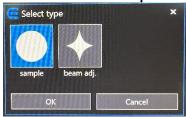


Set up the Exposure

Click on **Exposure** button this will open the EXP window below



- Click on Add Sample / Action Card, window seen below appears
- Select the sample click OK



- The below display appears to enter the necessary details
- Select the sample details as per your requirements
- Select the sample holder used during loading





- Click x to close the Menu
- The screen below appears



- Click on add beam Card,
- below menu appears



• Keep Beam Conditions and close the window by clicking on x,





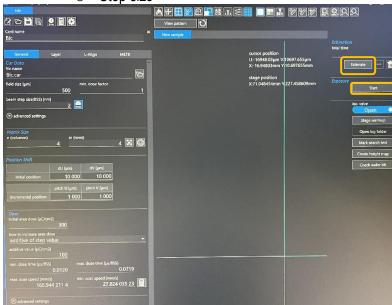
Click on Add Chip Card, the selection window seen below appears



- Select an option as per your exposure requirement Single or Matrix
- Enter details in the menu that appears
- For eg: if you have selected Matrix
- Choose the design or .car file
- Enter the exposure parameters:
 - o Position,
 - Matrix Size,
 - Matrix increment,
 - o Initial Dose,
 - Dose increment value and
 - Step size







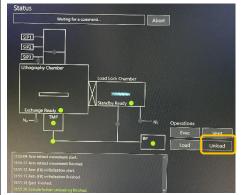
- Click on **Estimate** for the approximate exposure time
- Click on Start Button
- A message to save the Schedule file will appear
- Save the Schx file
- Exposure starts

Sample Unloading



Once exposure is complete, stage moves to FC or you can move it to exchange position





- Click unload
- Wait till you get the message "sample unload finished"
- Click the VENT button to open the load lock



• Take out the holder and place it on the holder stand





Close the loading chamber

and press EVAC button

• Log out from your session.

Sample ready for next processing step

- Unmount the sample from holder
- Store it in you Carrier box
- Place the holder in its respective box

Development [Ref. IM _160-P3.51B_WB2]

- Take your sample to WB2 for development
- Develop as per optimised time for a particular resist
- IPA Rinse (as per the resist used)
- DI water Rinse (if required)



TRANSPORT METHOD for hazardous substances, biological, animal, or radioactive materials or plant equipment

Samples transported around labs using closed plastic carrier boxes that can be locked

WASTE DISPOSAL

- 1. Waste bins available in the gowning area and yellow rooms
- 2. Any waste generated in EBL room to be disposed in the waste bins by the users
- 3. Sharps container placed in the yellow room for sharps disposal

COMPLETION OF WORK – List steps to make area safe (include clean up, any waste disposal & service/maintenance requirements)

Clean up after use

- 1. Clean up the lab area and working table surface after completion of work (no tapes/ broken substrate pieces/ used clean wipes should be lying around)
- 2. Keep the holder back in its respective box
- 3. Sharps waste goes in the sharp's bins placed in the yellow rooms
- 4. Deposit any waste generated other than sharps in the bins available in yellow room or gowning area.

Workers must read and completely understand the relevant equipment risk assessment and this instruction manual before they are allowed to work on the activity without direct supervision.